

IPC Technical Conference

**Yield Enhancement in BGA
Substrate Manufacturing and IC
Packaging**



Agenda

- ❖ Difference between AOI and AFI.
- ❖ The Challenge in AFI.
- ❖ Design elements in the Inspection.
- ❖ Typical defects.
- ❖ The 3rd Dimension- BGA Substrates for FC with CB.
- ❖ The Challenge in Technology and DI.



What is AFI

- ❖ Definition of HDI.
- ❖ AFI – Automated Final Inspection.
- ❖ How is it done today.
- ❖ Why is it not implemented in the PCB Market, final inspection.

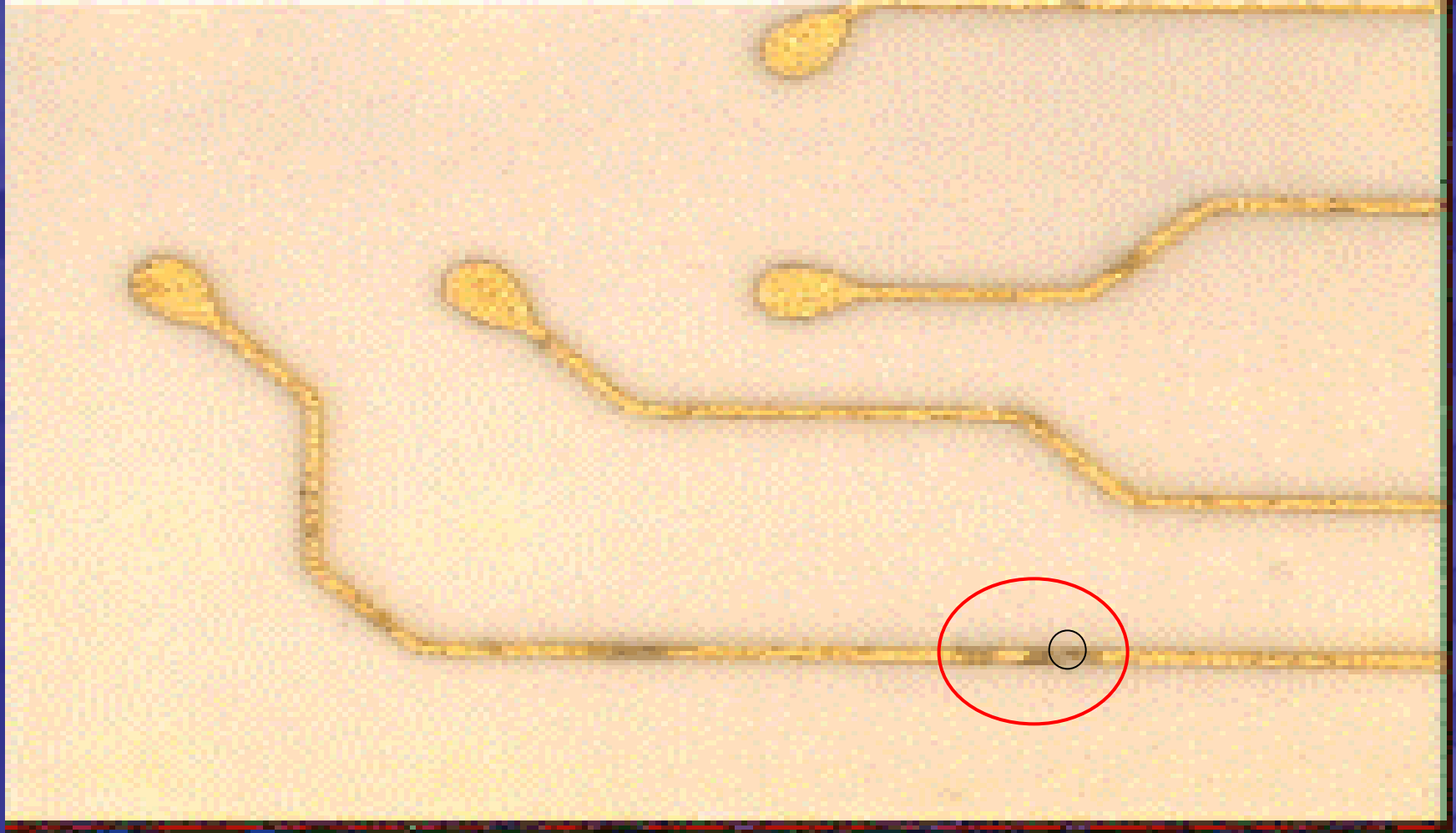


Interconnect – Surface Defects

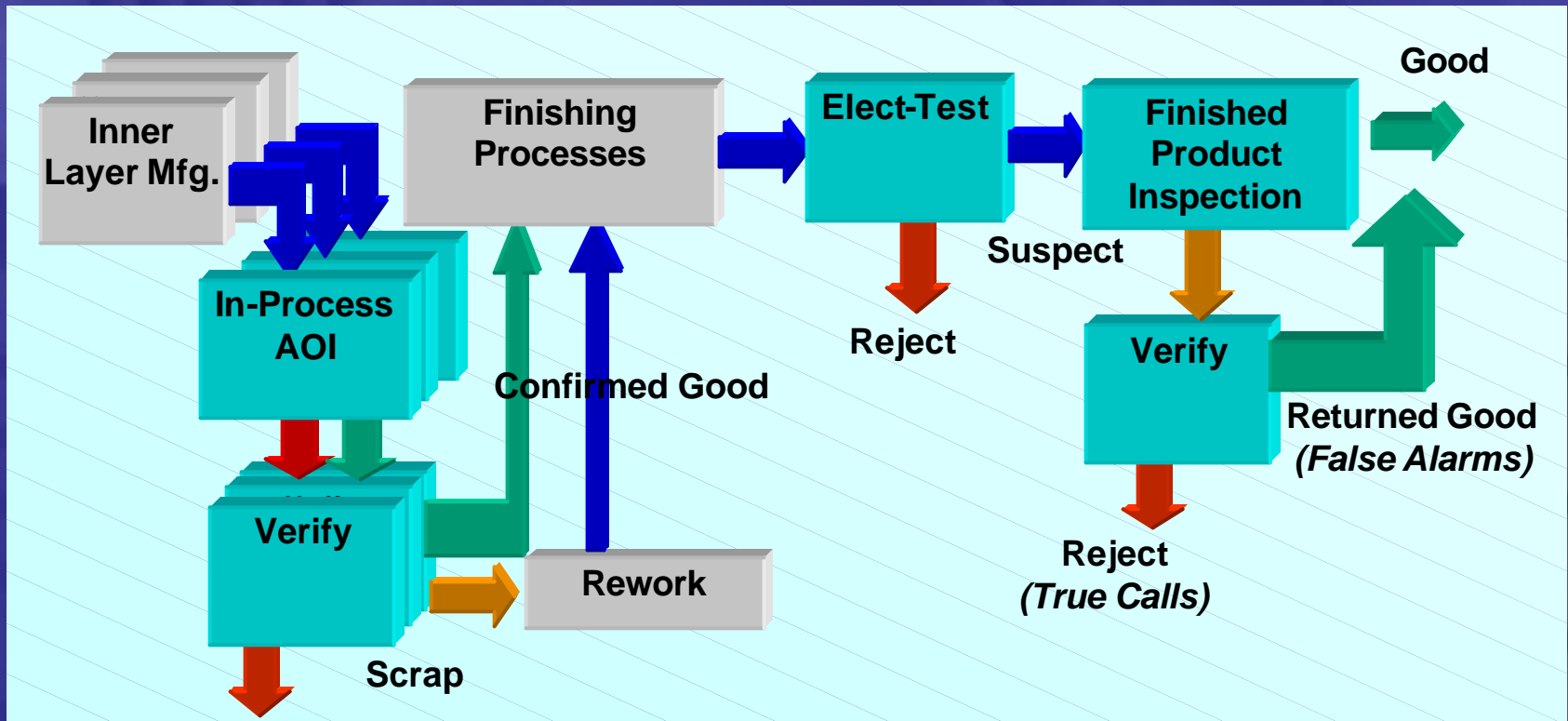
- ❖ In Process.
- ❖ Strive to isolate Cu and laminate.
- ❖ DRC and CAM – Interconnect.
- ❖ No attempt to identify Surface.
- ❖ Ignore surface anomalies.
- ❖ Final or Pre-Assembly.
- ❖ Inspection of Interconnect Pads.
- ❖ Flaws in Gold, OSP, SM, plating, Balls and Bumps.
- ❖ Flaws that may pass assembly, but fail in service life.



Interconnect – Surface Defects



Inspection through Process



The Unique Challenge of AFI

- ❖ AFI looks for interconnect surface defects, resulting from process or handling issues.
- ❖ Correlating the Type, Size, Design Location and extent on the interconnect reliability. Not Obvious.



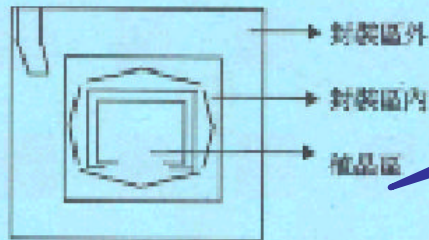
The Unique Challenge of AFI (2)

- ❖ The Inspection needs to differentiate all surface defects from their background.
- ❖ The need for Intelligence that would qualify their significance according to a pre set customer spec.



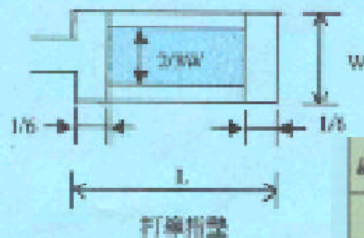
Customer Criteria

1.植晶區 (電力環以內區域，圖示如下)：



Where to look?

2.打線區定義 (未特別規定時，皆依此規範檢驗)：



區域	異常項目	代號	判定標準	Photo
	AOI前製程報廢)		不允收	

區域	異常項目	代號	判定標準	Photo
	變色污染	35	金手指重要區：不允收 電力環重要區：1.不可大於2*2mil，電力環單邊以一類為限 2.電力環4個角落非重要區不管	
	solder pad：	45	電力環重要區：1.不可大於2*2mil，電力環單邊以一類為限 2.電力環4個角落非重要區不管 不可大於面積的5%	
	導膠口：		不可大於面積100mil*100mil	

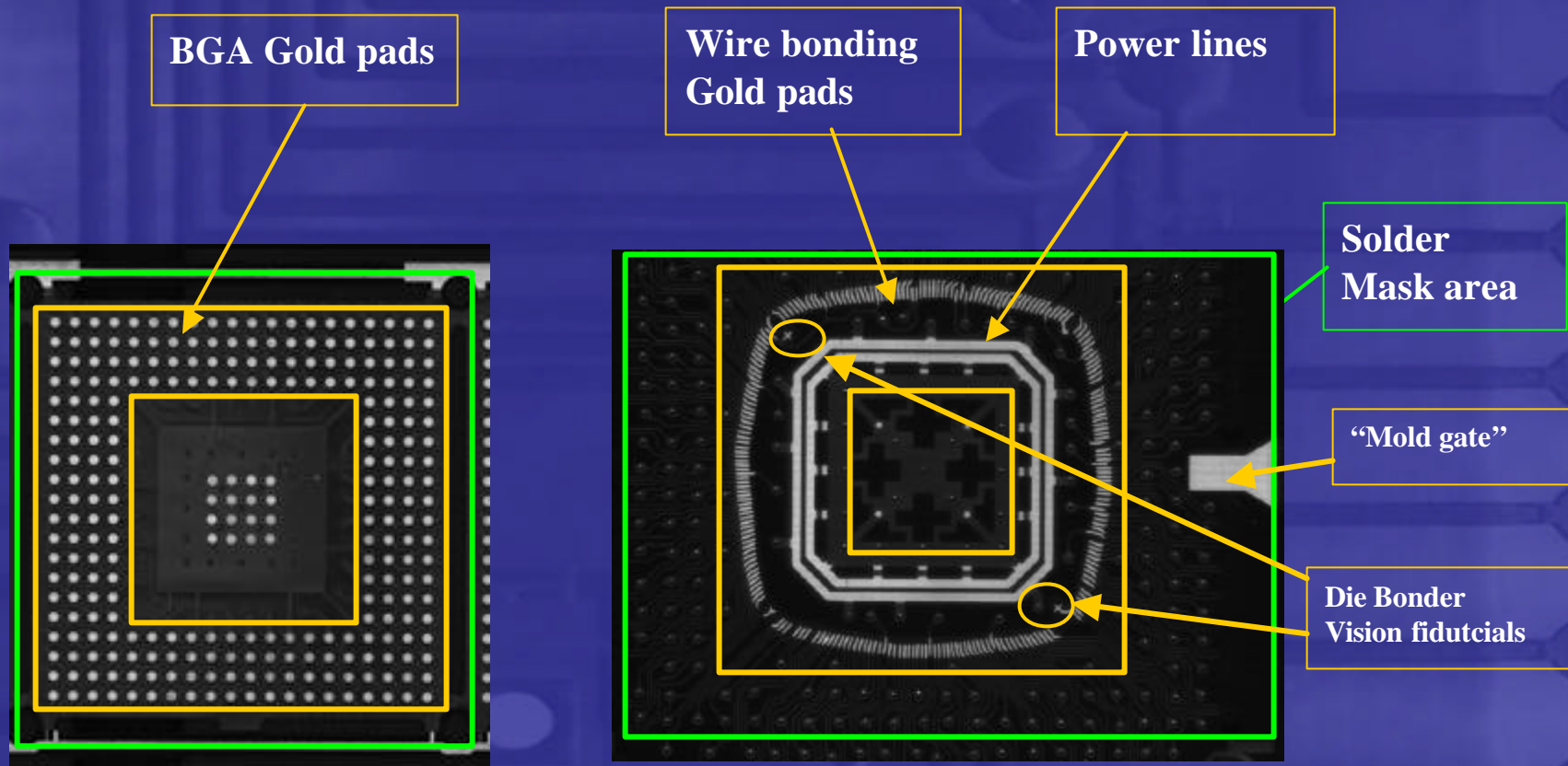
What to detect?

The heart of things

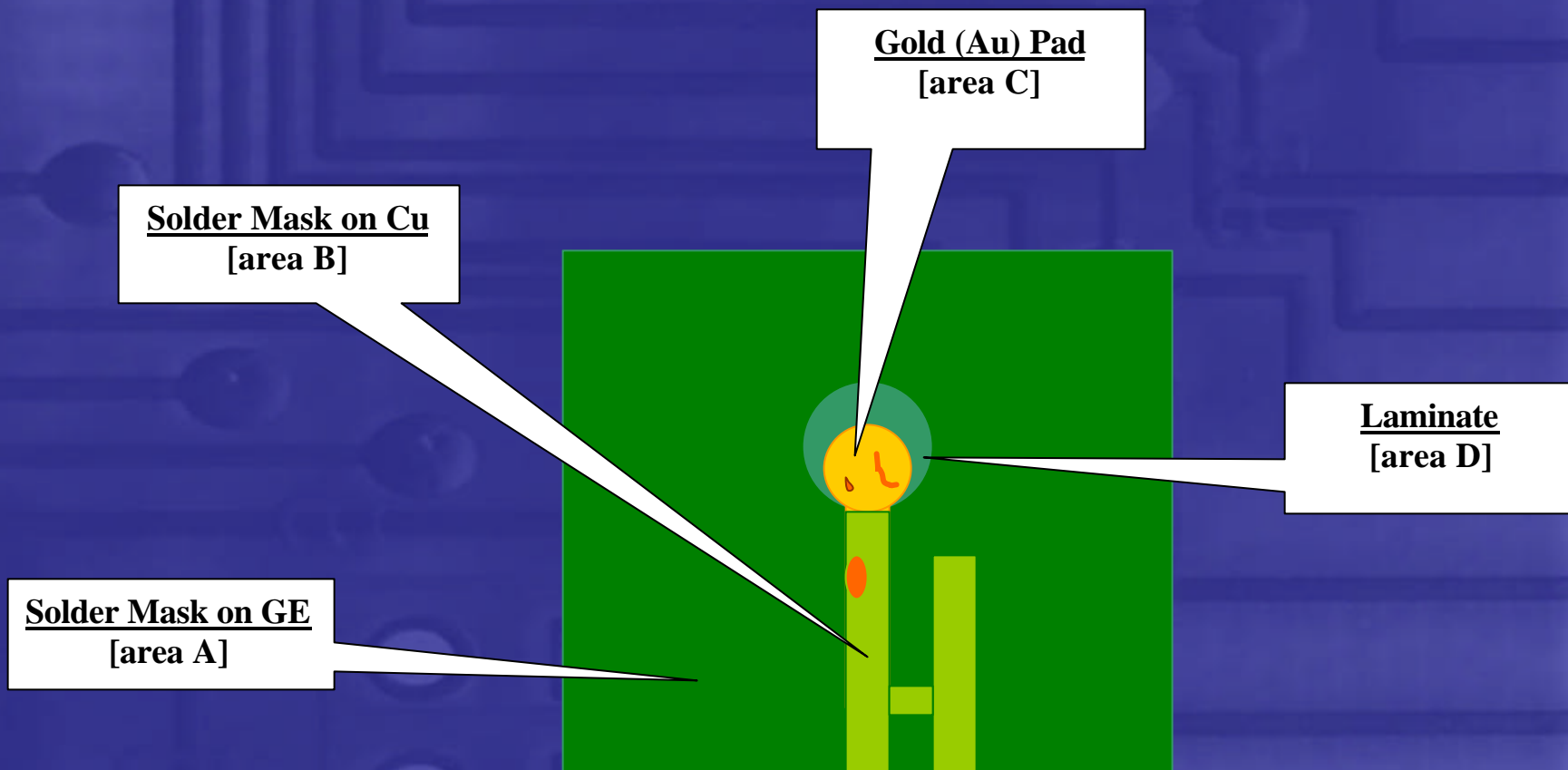
- ❖ **Problem** - Subjective judgment due to uncertainty in defect reporting, due to non-deterministic defect description in specs and variety of defects.
- ❖ **The Ideal** – The Inspection tool should effectively , implement qualities criteria, and replace human decision.



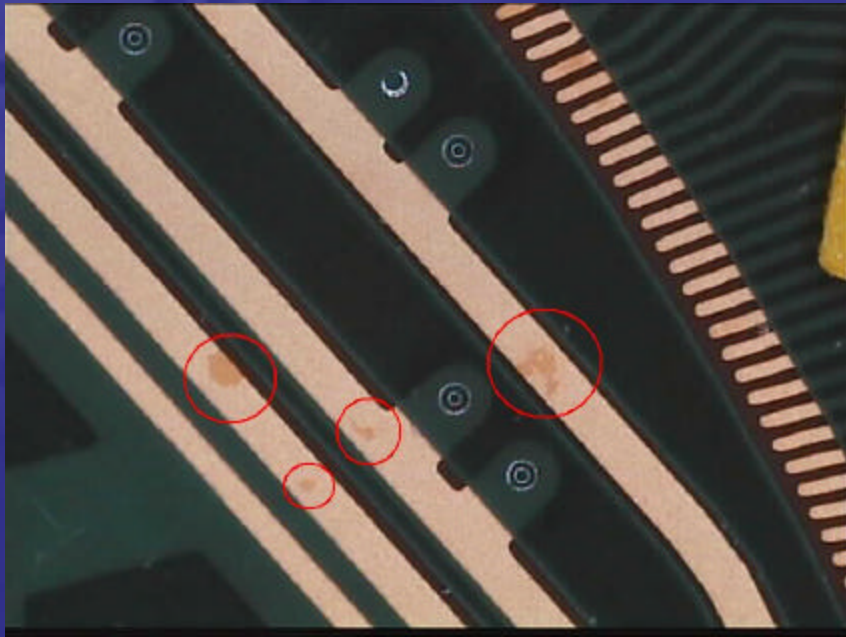
Design Elements of Inspection



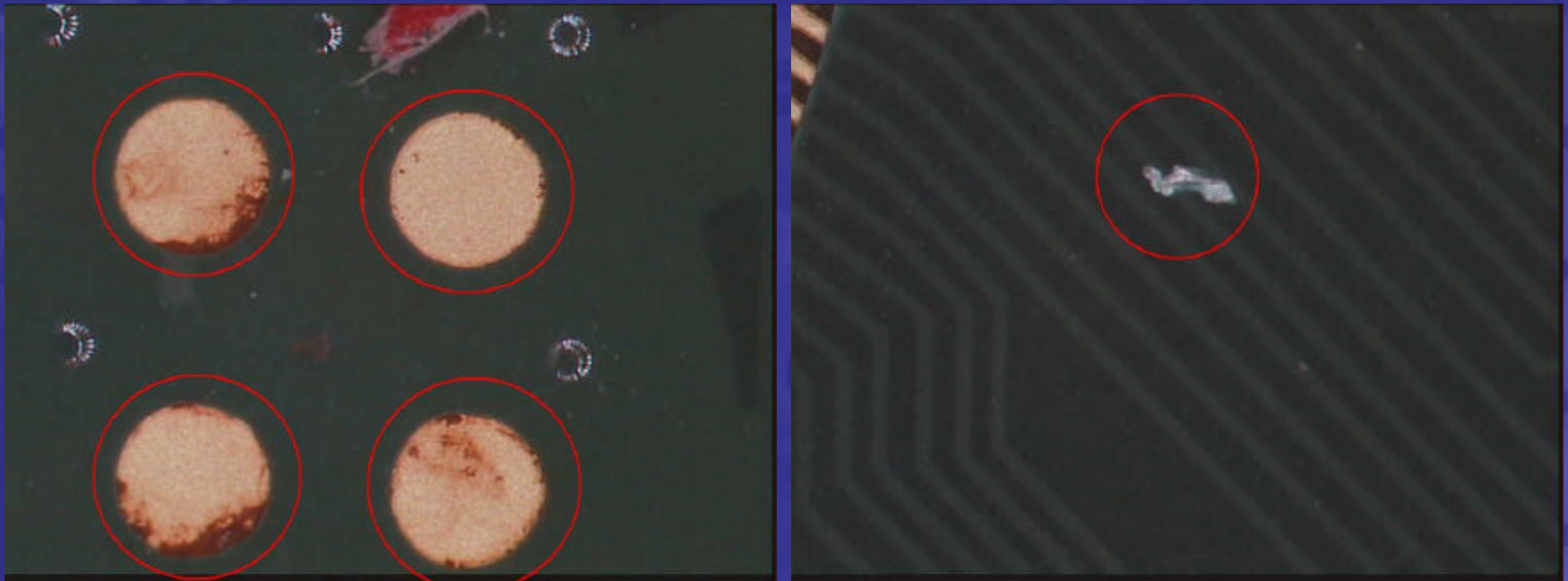
Different Areas of Inspection



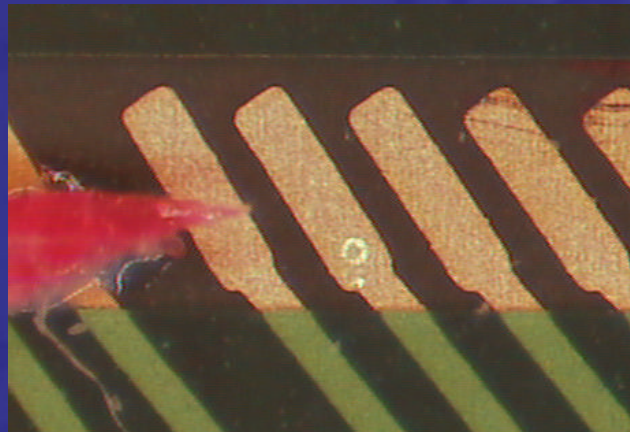
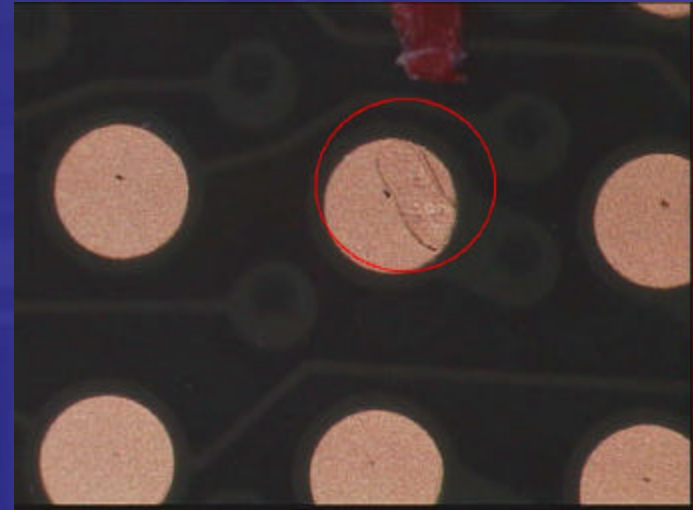
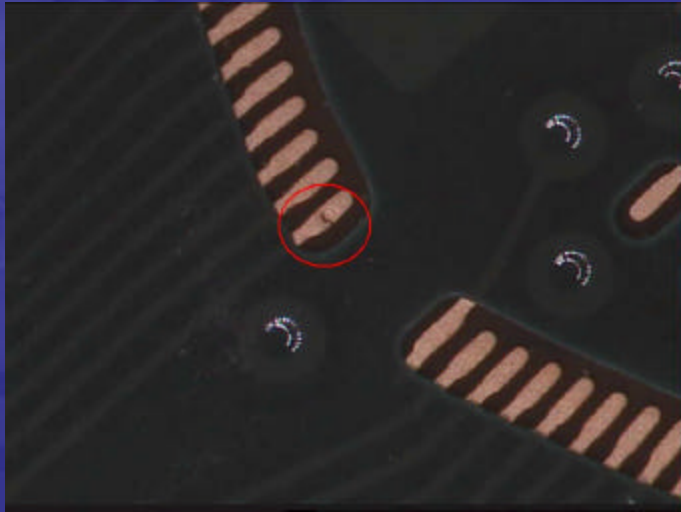
Discoloration



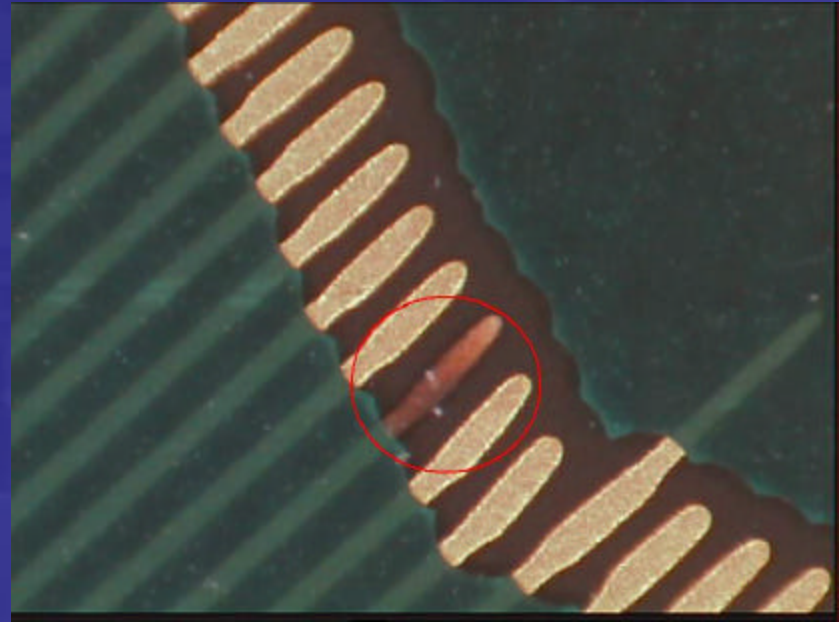
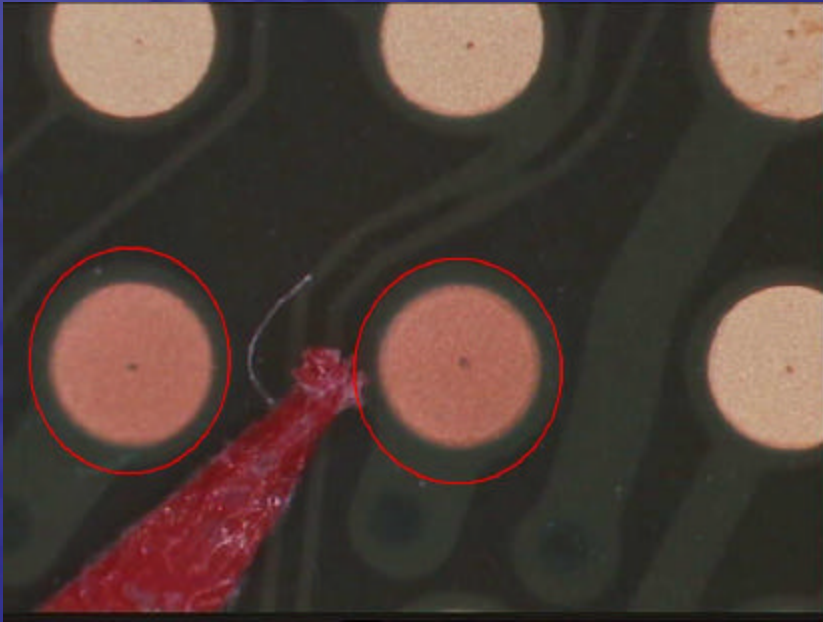
Contamination and Foreign Materials



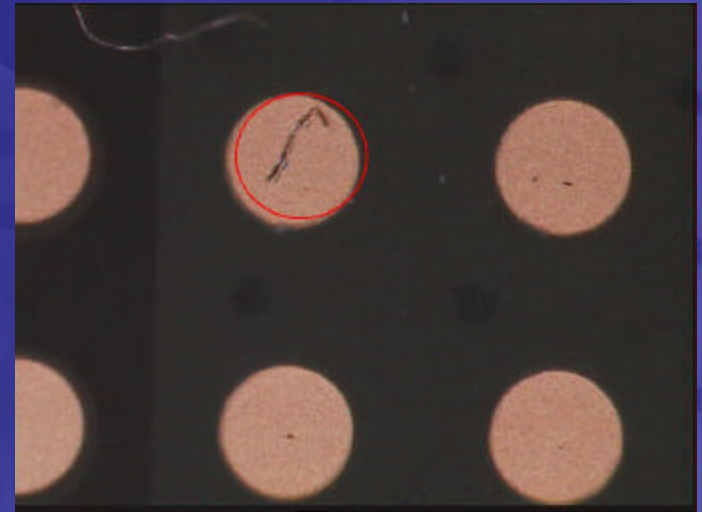
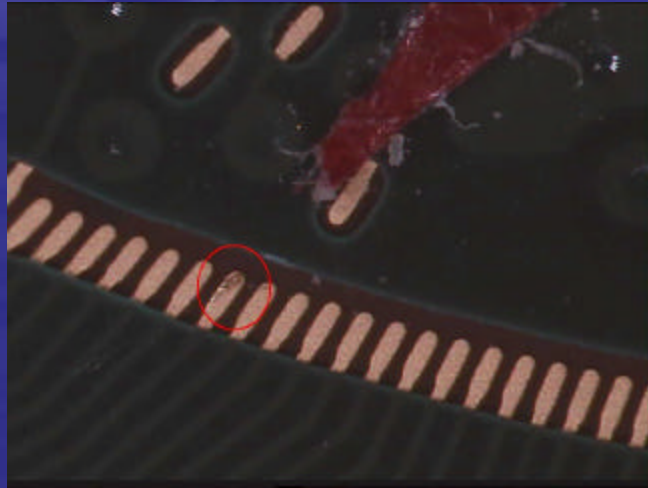
Dish-down and Dents



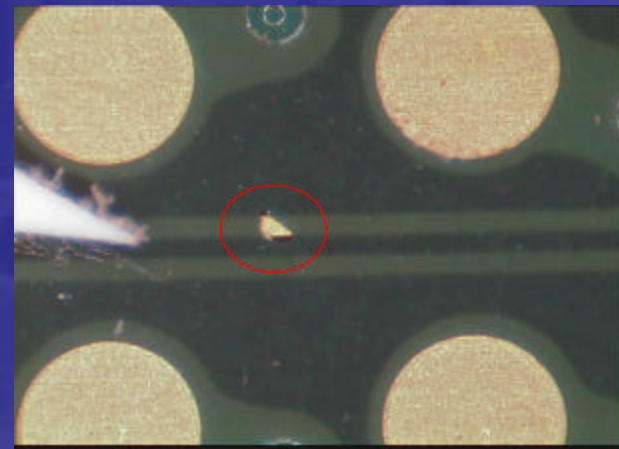
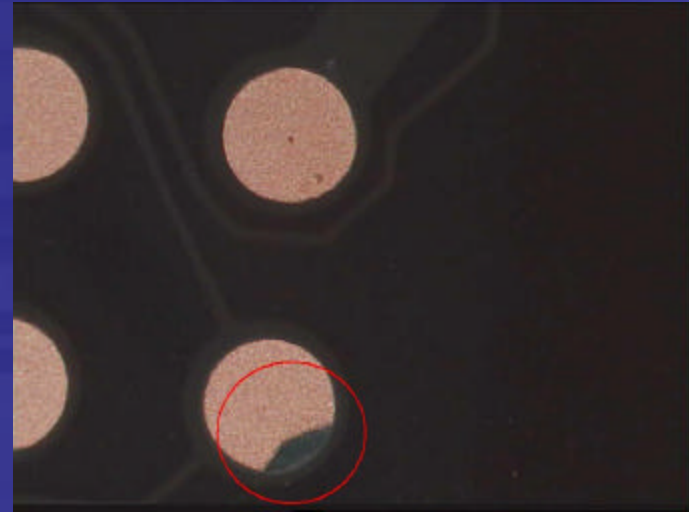
Bare Copper / Skip Plating



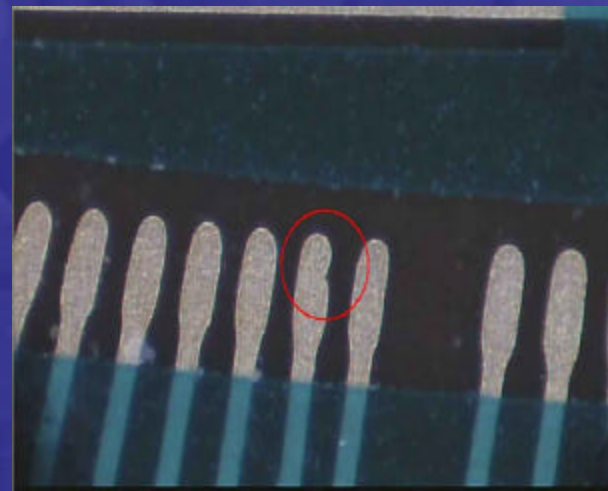
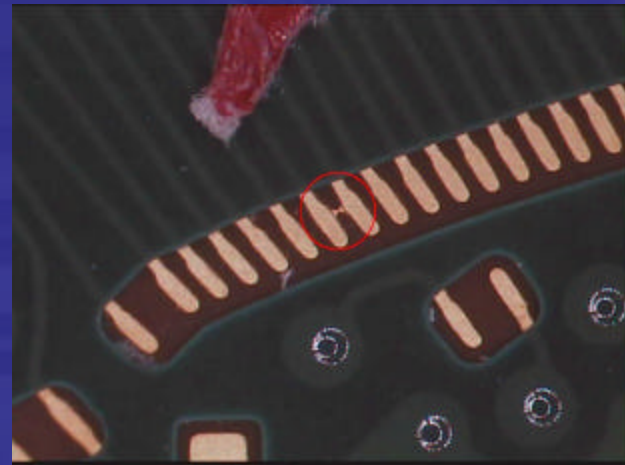
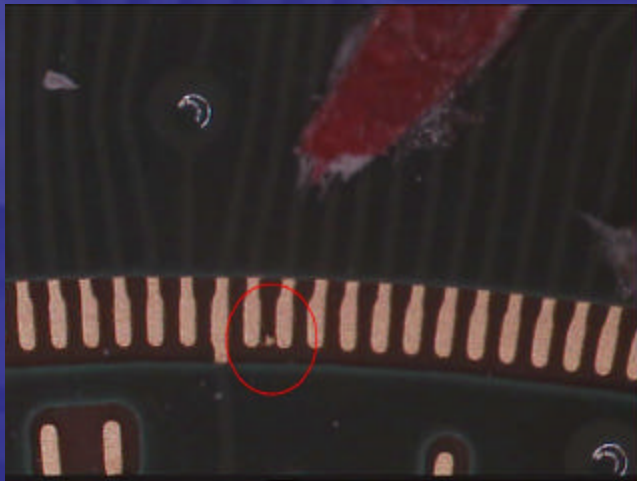
Scratches on Gold and SM



Solder Mask violations and Solder Mask peeling

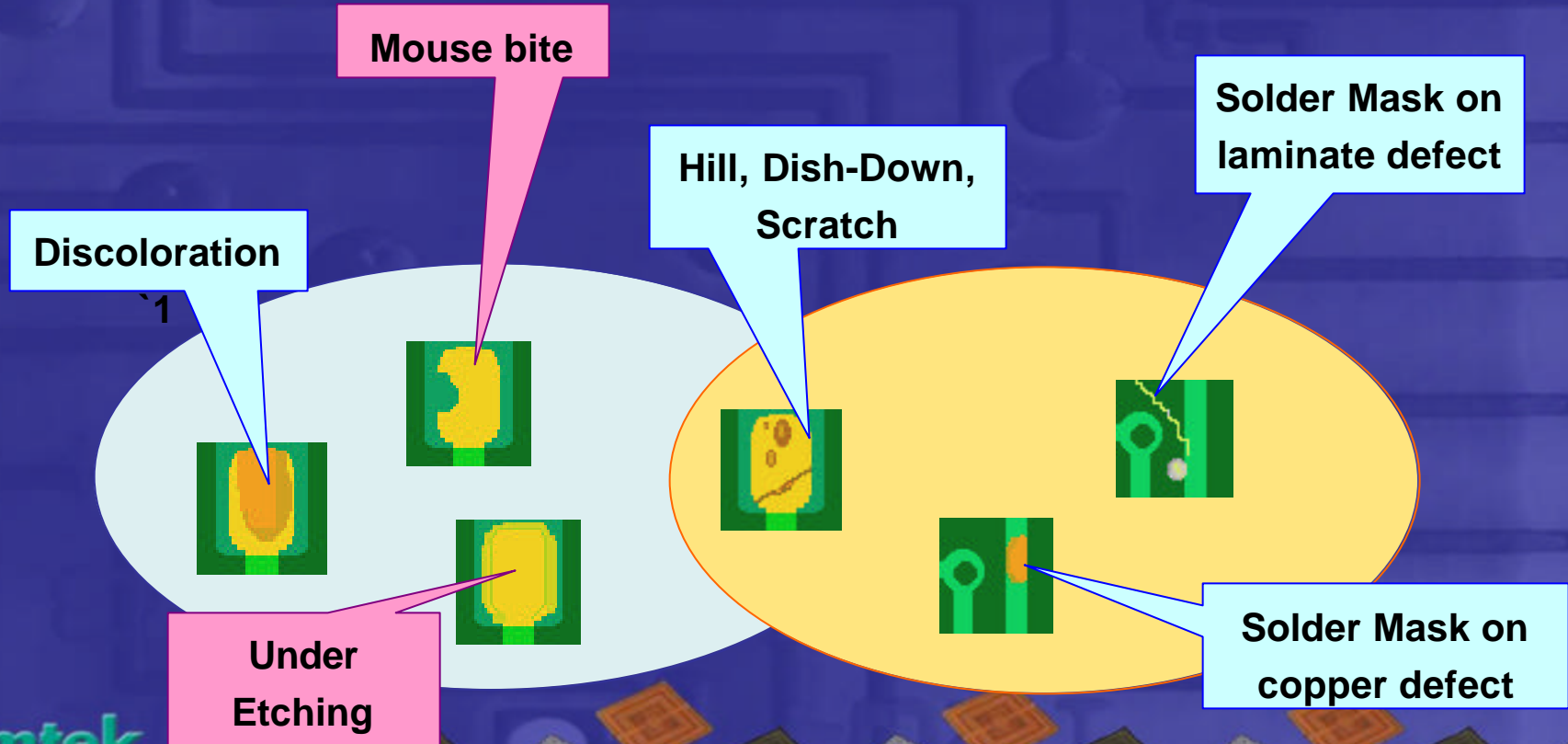


Extra Copper/Gold and Shape violations



Sorting AFI Defects

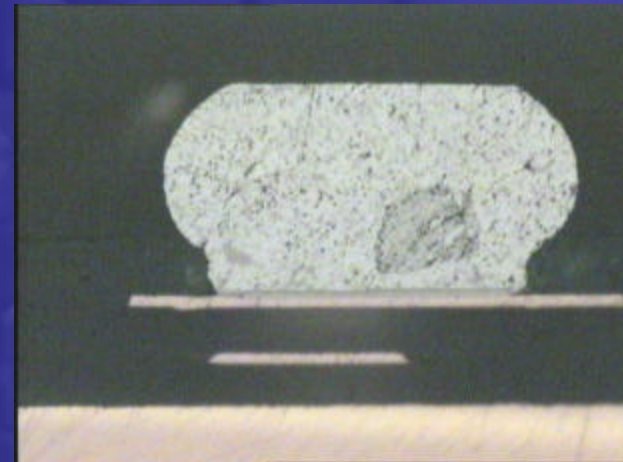
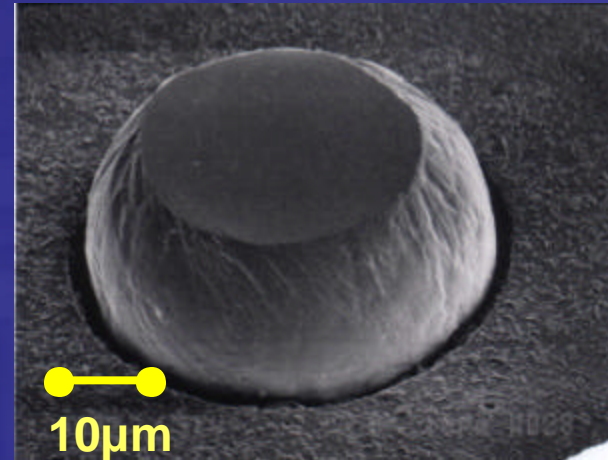
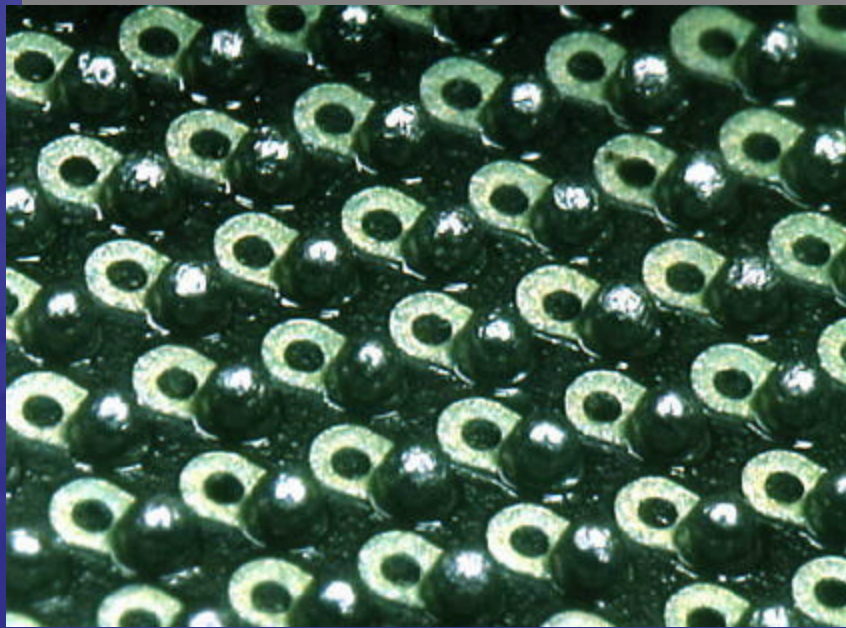
Pegasus provides defects Auto Classification capability and SPC analysis



The Third (3rd) Dimension of Flip-Chip

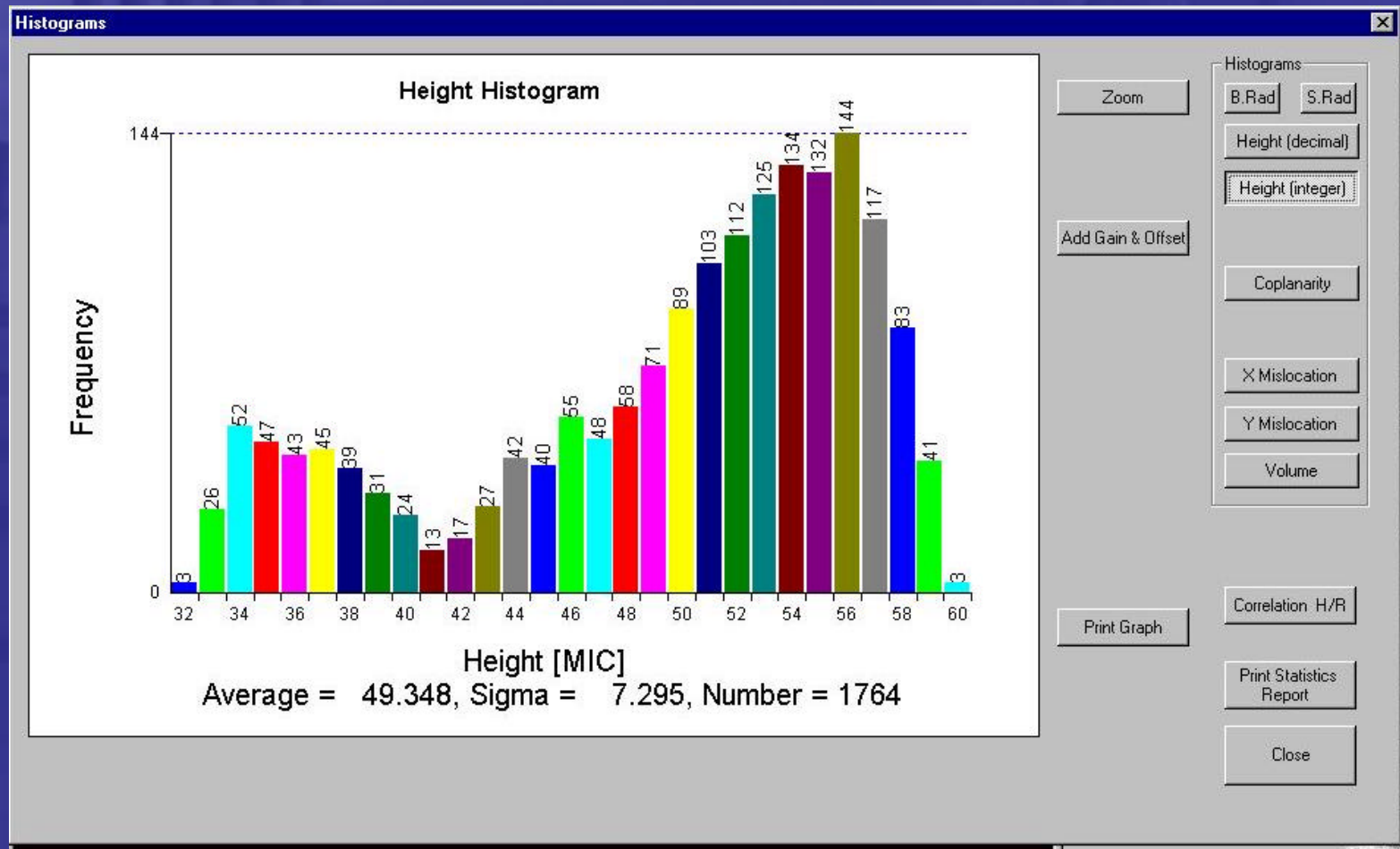


Bumps on Substrates

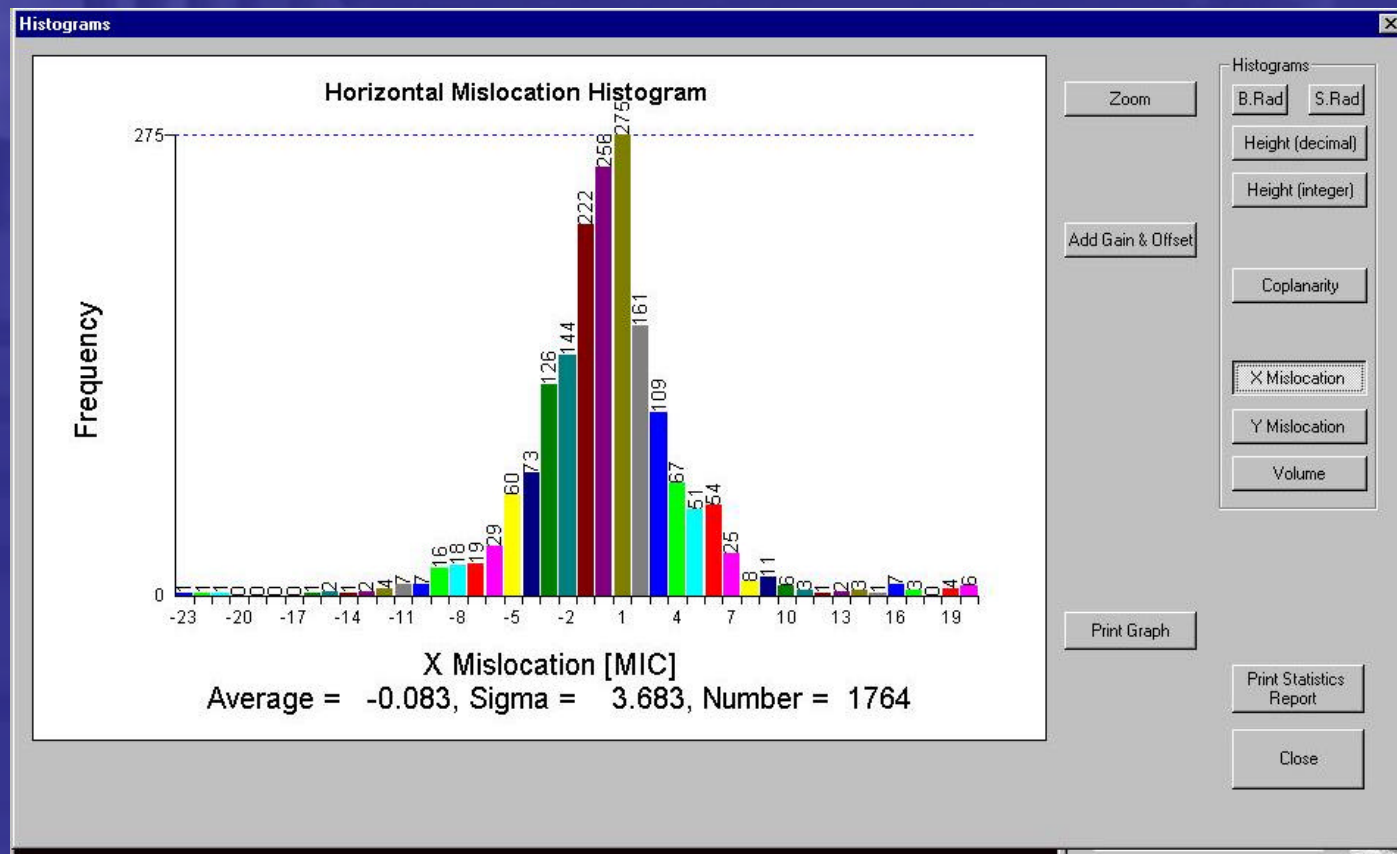


Flattened Solder Bump

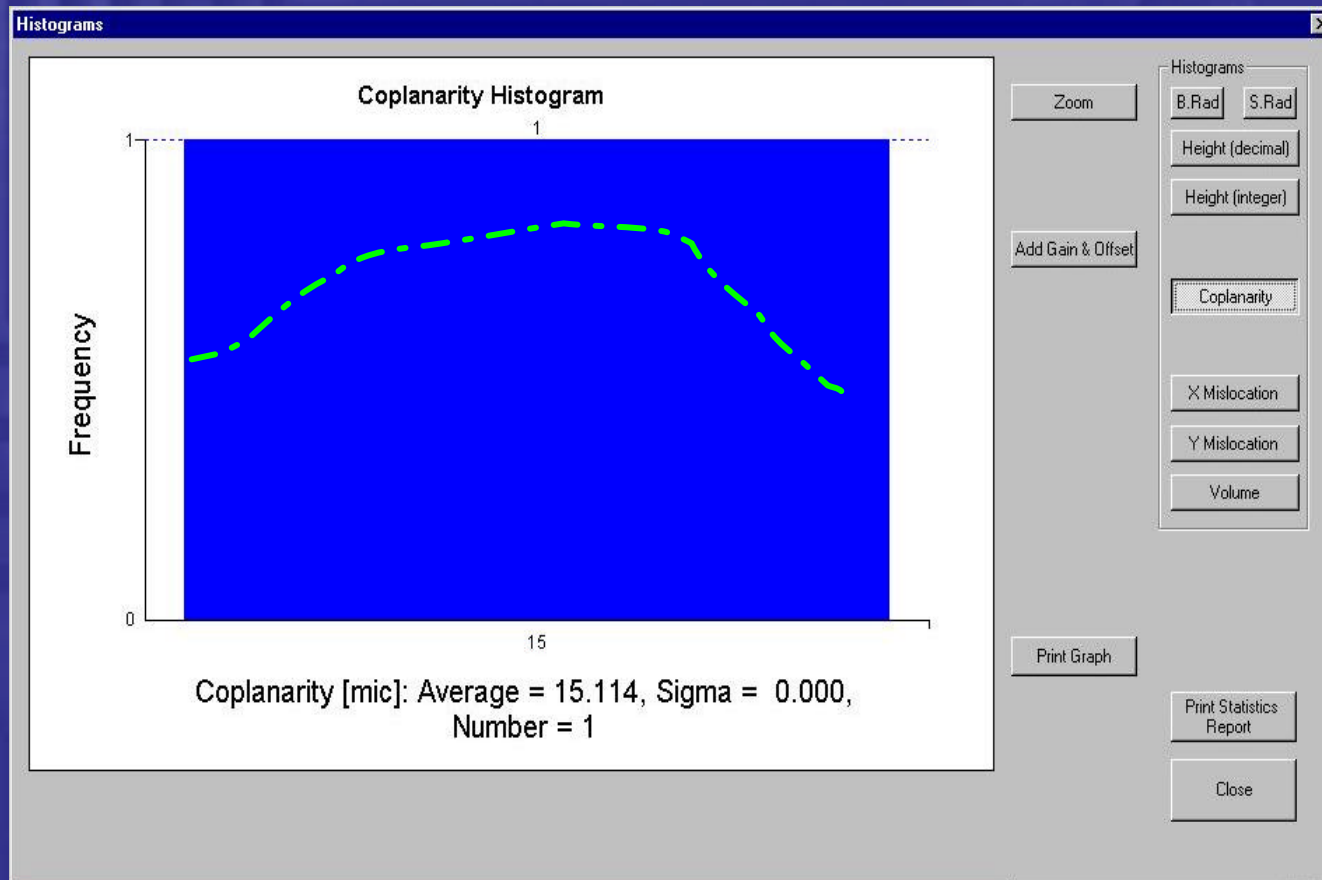
SPC - Bumps Height Metrology



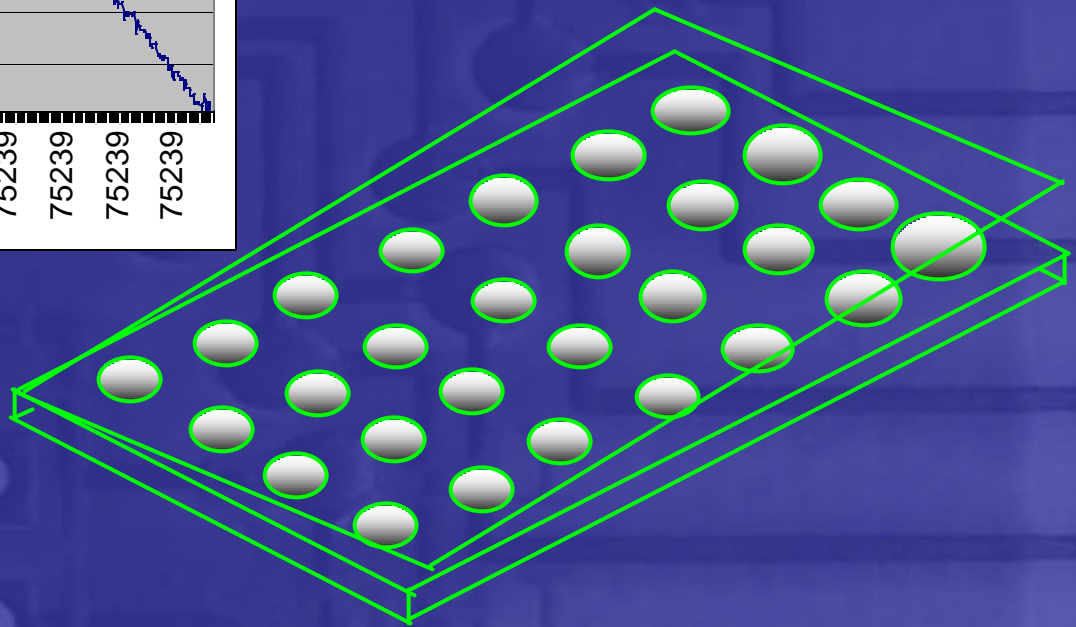
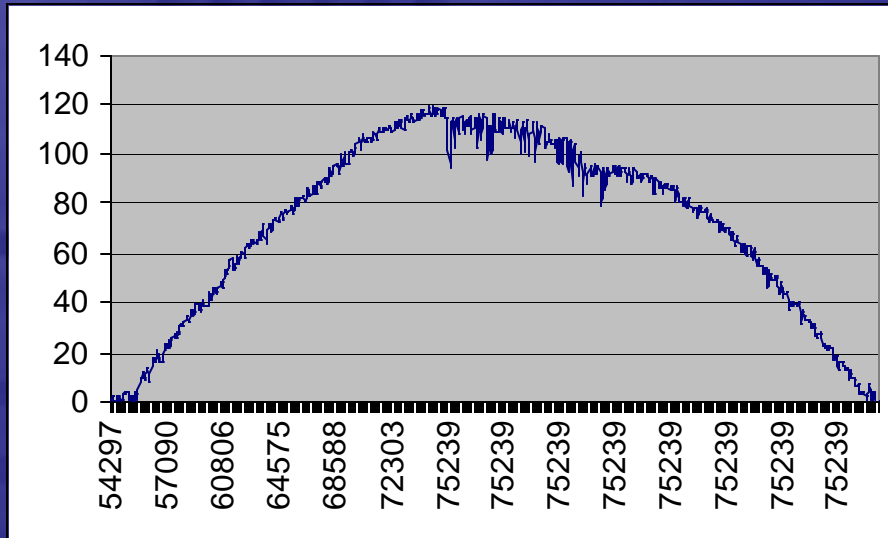
SPC - Wrong Location in X axes



SPC - Bumps Co-Planarity



SPC - Substrate Warpage



The challenge in the Technology



The Trade Off between Detection -- False Alarm

$$DI = \left[1 - \frac{FA}{TC} \right] \left[1 - \frac{MD}{KD} \right]$$

DI – Detection Index

FA – Number of False Alarm Calls.

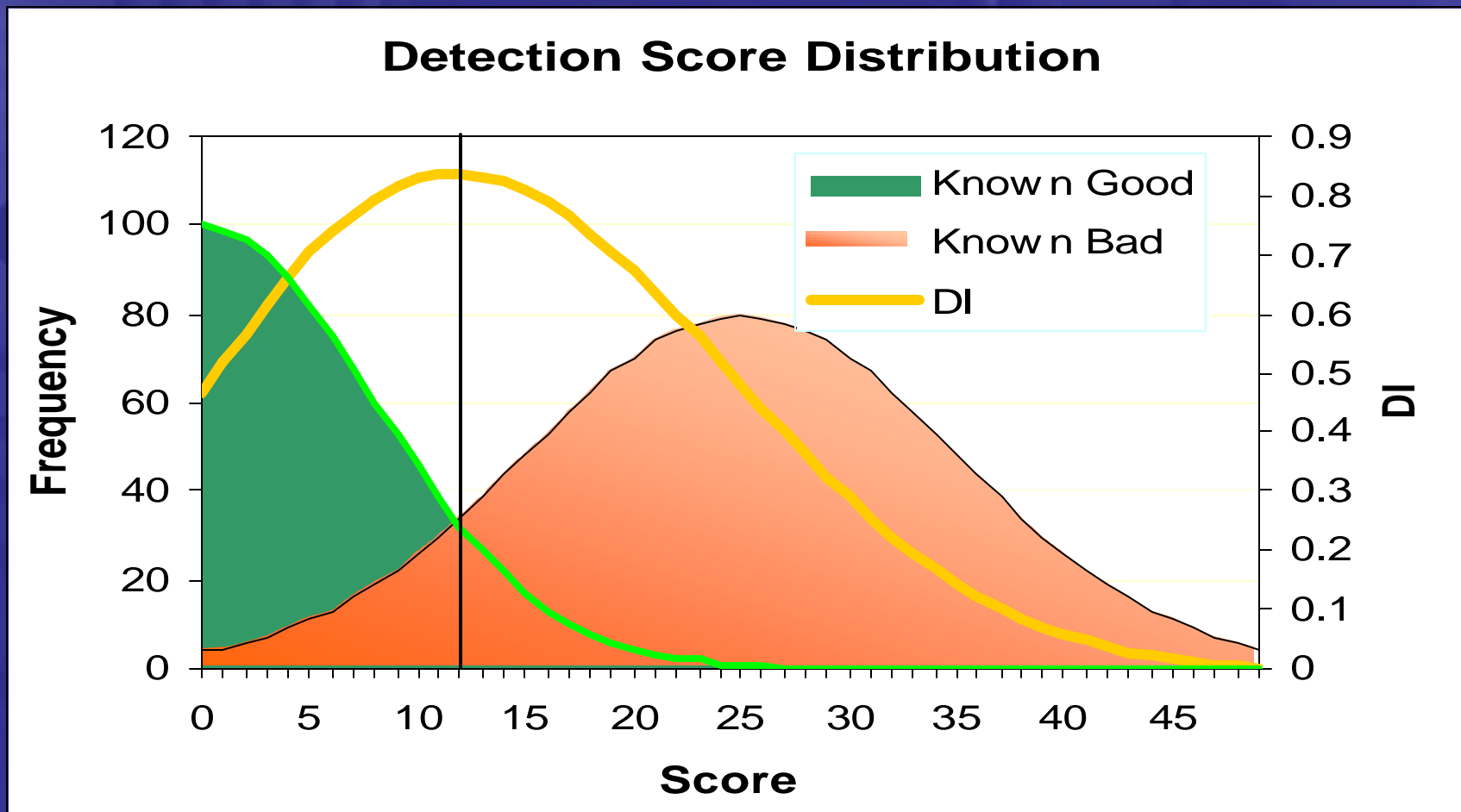
TC – Total number of calls.

MD – Number of Missed Defects.

KD – Number of Known Defects.

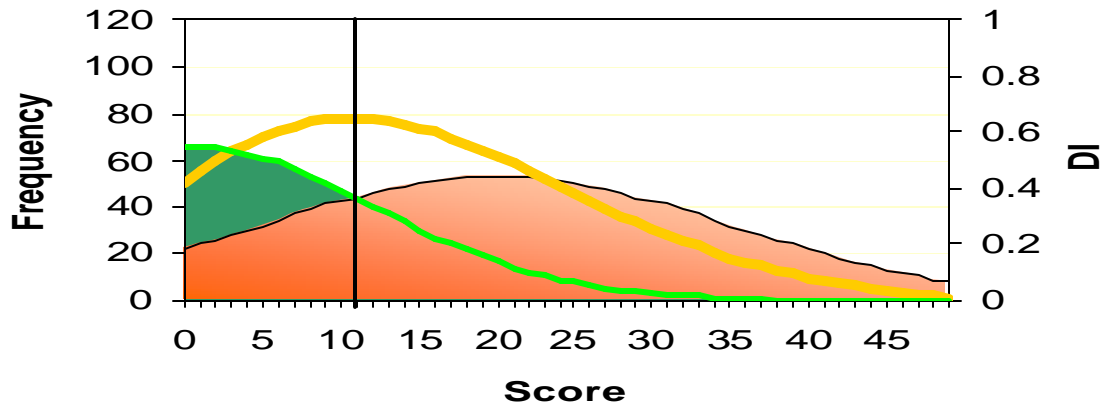


Detection Score Distribution

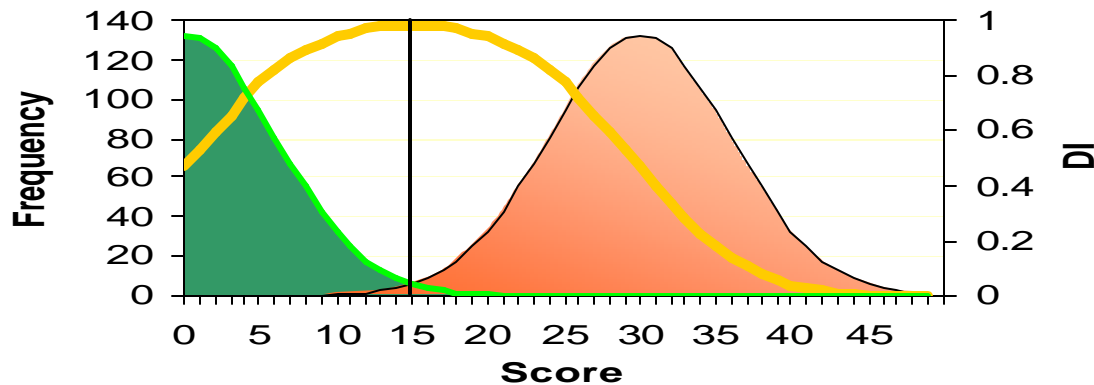


Low - High Separation System

Low Separation System



High Separation System



Thank You!

Yossi Pinhassi

Udi Efrat

Moti Yanuka

